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APPLICATION NO.	FILING DATE		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/774,412	02/10/2004		Hitoshi Miyano	25-262	9894
75	590	06/27/2005		EXAMINER	
Arnold Interna P.O. BOX 129	ational		SUGARMAN, SCOTT J		
Great Falls, VA	A 22066			ART UNIT	PAPER NUMBER
•				2873	

DATE MAILED: 06/27/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

				AL			
		Application No.	Applicant(s)				
		10/774,412	MIYANO				
	Office Action Summary	Examiner	Art Unit				
		Scott J. Sugarman	2873				
Period fo	The MAILING DATE of this communication app or Reply	pears on the cover sheet with	the correspondence add	iress			
THE I - Exter after - If the - If NO - Failu Any r	ORTENED STATUTORY PERIOD FOR REPL' MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period or the to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply y within the statutory minimum of thirty (3 will apply and will expire SIX (6) MONTH: , cause the application to become ABAN	be timely filed  O) days will be considered timely.  S from the mailing date of this condoned.  DONED (35 U.S.C. § 133).				
Status							
1)	Responsive to communication(s) filed on						
2a)□	This action is <b>FINAL</b> . 2b)⊠ This	action is non-final.					
3)□	Since this application is in condition for allowar	nce except for formal matters	s, prosecution as to the	merits is			
	closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 1	1, 453 O.G. 213.	-			
Dispositi	ion of Claims						
4)🖂	Claim(s) 1-16 is/are pending in the application						
	4a) Of the above claim(s) is/are withdrawn from consideration.						
5)□	Claim(s) is/are allowed.						
	Claim(s) <u>1-16</u> is/are rejected.						
7)	Claim(s) is/are objected to.						
8)□	Claim(s) are subject to restriction and/o	r election requirement.					
Applicati	on Papers			•			
9)□	The specification is objected to by the Examine	er.					
10)🖂	☑ The drawing(s) filed on 10 February 2004 is/are: a)☑ accepted or b)☐ objected to by the Examiner.						
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11)	The oath or declaration is objected to by the Ex	caminer. Note the attached C	office Action or form PT	O-152.			
Priority u	ınder 35 U.S.C. § 119	•					
_	Acknowledgment is made of a claim for foreign  ☐ All b)☐ Some * c)☐ None of:  1.☐ Certified copies of the priority document	s have been received.					
	2. Certified copies of the priority document		· · · · · · · · · · · · · · · · · · ·				
	3. Copies of the certified copies of the prior		ceived in this National S	Stage			
	application from the International Bureau						
* 8	See the attached detailed Office action for a list	of the certified copies not rec	ceived.				
Attachment	t(s)						
	e of References Cited (PTO-892)	4) Interview Sum	mary (PTO-413)				
2) 🔲 Notic	e of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/M	lail Date				
	nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) r No(s)/Mail Date <u>2-10-04</u> .	5)	mal Patent Application (PTO-	·152)			

#### **DETAILED ACTION**

## **Priority**

Receipt is acknowledged of papers submitted under 35 U.S.C. 119(a)-(d), which papers have been placed of record in the file.

## Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1-4 are rejected under 35 U.S.C. 102(b) as being anticipated by Fujii (JP 2003029142A). Fujii teaches (in Embodiment 1; Fig. 1) an endoscope objective having a three-group, three-lens construction having, in order from the object side, a first lens element of negative refractive power and either a meniscus or plano-concave shape with its concave surface on the image side; a stop; a second lens element of positive refractive power and a plano-convex shape with its convex surface on the image side; and a third lens element of positive refractive power and a plano-convex shape with its convex surface on the object side. In Fujii, (col. 4, lines 28-39), the first condition of |f1 / f| is 2.03 which is between the claimed values of 2.00 and 3.00. In Fujii, (col. 4, lines 28-39), the second condition of |f1 / D2| is 5.88 which is between the claimed values of 2.50 and 7.5. In Fujii, (col. 4, lines 28-39), the third condition of |D3 / R4| is

0.91 which is less than 1.00. The index of the first lens element is greater than 1.8 (1.883).

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 5-16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Fujii. Fujii teach the recited structure and numerical limitation as recited above. However, Fujii does not specifically teach that the lens elements can be made by a molding process or a grinding process. Since these are the generally the only way lenses are made (by molding or grinding), it would have been obvious to one of ordinary skill in the art to make the lenses of Fujii by molding or grinding.

#### Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Michaels (US 6,038,079) is cited to show an objective system for an endoscope having the claimed structure in Embodiments 8, 9 and 11 (Figs. 8, 9 and 11). In Michaels, the index of refraction for sapphire that was used in the calculations was 1.76. However, Michaels does not meet all of the conditions as recited in claim 1.

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Nagaoka (US 6,256,155), Kikuchi (US 5,359,456) and Igarashi (US 5,119,238) are all

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cited to show some similar structure utilized in endoscope objectives.

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Scott J. Sugarman whose telephone number is

(571)272-2340.

The fax phone number for the organization where this application or proceeding

is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the

Patent Application Information Retrieval (PAIR) system. Status information for

published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only.

For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

Sis June 23, 2005